

Photosensitive resin patterning

Processable film type

- ① Resist, transparent resist, polyimide, resin black, photosensitive Ag, etc.
- ② Processing size
 - MAX: 300mm × 300mm (Spin coater application)
 - * Effective area: ϕ 300mm

③ Processing example

| | Line | Space |
|-------------|------------|------------|
| Resist | 3 μ m | 3 μ m |
| polyimide | 10 μ m | 10 μ m |
| resin black | 7 μ m | 15 μ m |
| Ag, etc. | 10 μ m | 10 μ m |

